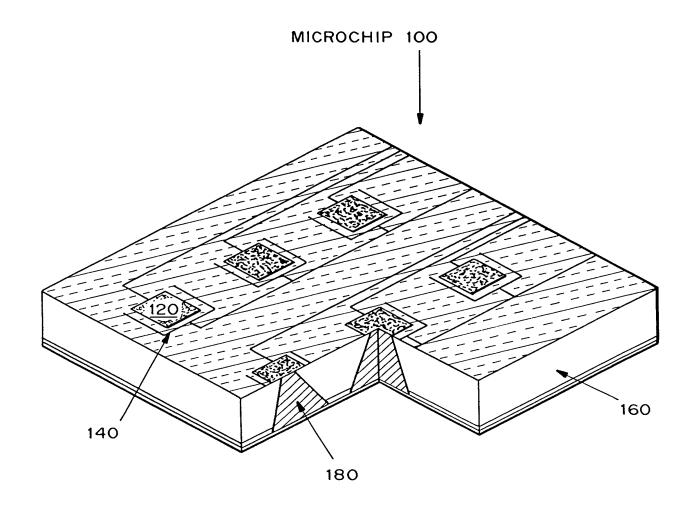


RELEASE SYSTEM CONTAINING THE DRUG OR OTHER MOLECULE

RESERVOIR CAP MATERIAL INSULATOR/ETCH MASK MATERIAL

F1G. 4

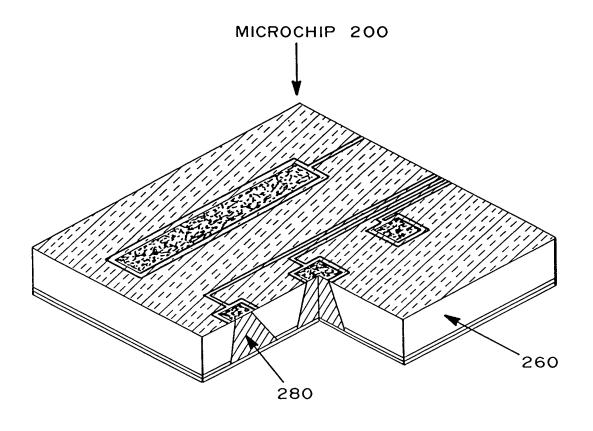


RELEASE SYSTEM CONTAINING THE DRUG OR OTHER MOLECULE

ANODE AND CATHODE MATERIAL

INSULATOR/ETCH MASK MATERIAL

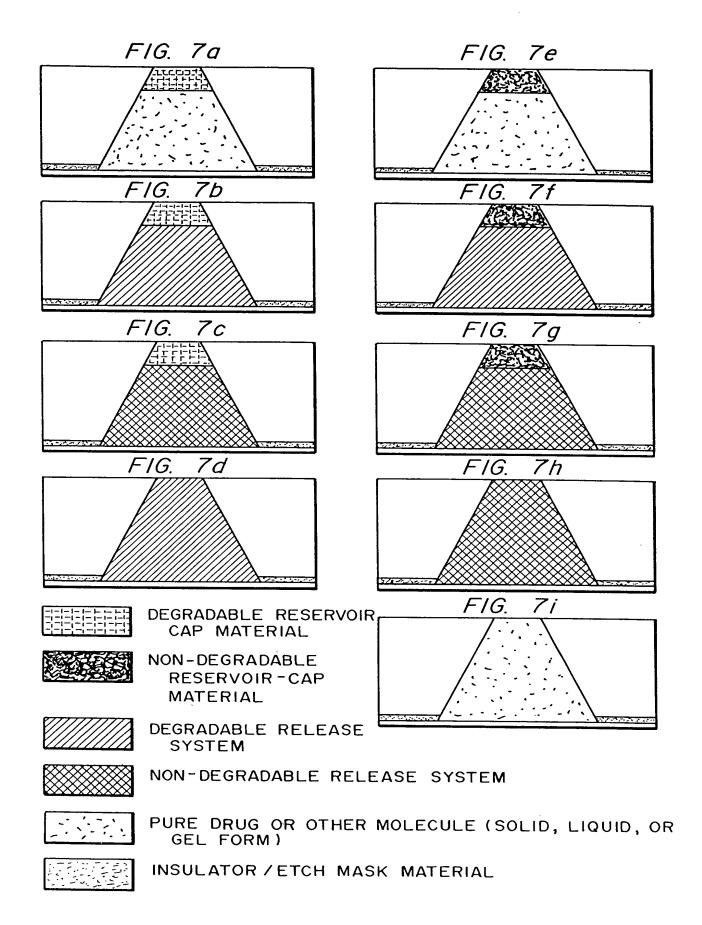
F/G. 5

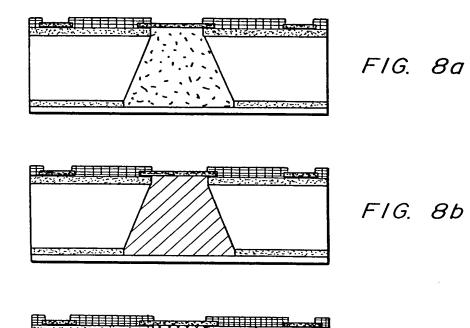


RELEASE SYSTEM CONTAINING THE DRUG OR OTHER MOLECULE

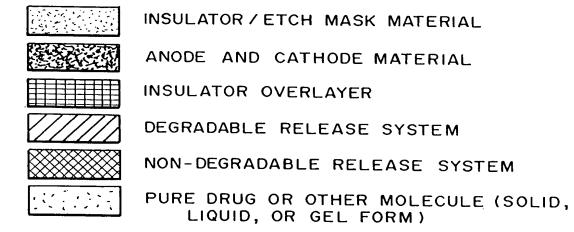
ANODE AND CATHODE MATERIAL

INSULATOR OVERLAYER AND ETCH MASK MATERIAL





F1G. 8c



600

.700

830b